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INFORMATION DISCLOSURE STATEMENT BY APPLICANT

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Complete if Known Application Number 10/664303 Filing Date September 16, 2003 First Named Inventor Andrew Edward Feiring Et. Al. Art Unit 1751 **Examiner Name** Unknown Attorney Docket Number CL2275USNA

Examiner	Cite	Degree and M.	U. S. PATENT D	OCUMENTS	
Initials*	No.1	Number-Kind Code <sup>2 (* known)</sup> US- 2002 (24.00 4.00	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
(A		2002/0102490	08-01-2002	Ito et al.	
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	Complete if Known
Application Number	10/664303
Filing Date	September 16, 2003
First Named Inventor	ANDREW EDWARD FEIRING ET. AL.
Group Art Unit	1751
Examiner Name	Unknown
Attorney Docket Number	CL2275USNA

	γ	OTHER PRIOR ART NON PATENT LITERATURE DOCUMENTS	
Examiner Initials *	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T <sup>2</sup>
w		"Synthesis and Evaluation of Alicyclic Backbone Polymers for 193 nm Lithography" Hiroshi Ito, Norbert Seehof, Rikiya Sato, Tomonari Nakayama and Mitsuru Ueda American Chemical Society (1998) Chapter 16, pp208-223	
W		Journal Article (Abstract) "Vinyl Polymerization. LXXXVIII. Polymerization and Copolymerization of Endo- and Exo-5-Cyanobicyclo[2.2.1]hept-2-ene" Imoto, Minoru; Otsu, Takayuki; Ito, Toshio, Kogyo Kagaku Zasshi (1964), 67(6), 961-5	
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M		Viacheslav A. Petrov, Synthesis 2002, No.15, 2225-2231, ISSN0039-7881 "Synthesis of Polyfluorinated Tertiary Alcohols Using Ring Opening Reactions of 2,2-Bis(trifluoromethyl)Oxirane"	
W		Richard A. Bartsch and John Gun Lee, J. Org. Chem (1991) 212-217 "Stereochemistry of Base-Promoted 1,2-Elimination from exo-2-Bicyclo[2.2.1]heptyl Tosylate and Choride"	

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Examiner

7. Ashton

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## INFORMATION DISCLOSURE STATEMENT BY APPLICANT

Complete if Known **Application Number** 10/664303 Filing Date September 18, 2003 First Named Inventor ANDREW EDWARD FEIRING ET. AL Group Art Unit 1751 Examiner Name Unknown Attorney Docket Number CL2275USNA

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OTHER PRIOR ART -- NON PATENT LITERATURE DOCUMENTS Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of Cite Examiner the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue T 2 Initials 1 No.1 number(s), publisher, city and/or country where published. Neal O. Brace, Journal of Fluorine Chemistry, 20 (1982) 313-327 Some Approaches to the Synthesis of Fluorinated Alcohols and Esters. M II. Use of F-Alkyl lodines for the Synthesis of F-Alkyl Alkanois" Raymond J. Hung et al., "Resist Materials for 157 nm Microlithography: An Update" W Proceedings of SPIE Vol. 4345 (2001) 385-395  $\Box$ John D. Roberts, E.R. Trumbull, Jr., Winnifred Bennett and Rose Armstrong, "The Reaction of Norbornylene with N-Bromosuccinimide. Nortricyclene and its Derivatives" (1950) Vol 72, 3116-3124 Y AB Contribution from the Department of Chemistry and Laboratory of Nuclear Science and Engineering, Massachusetts Institute of Technology Brian C. Trinque et al., J. Vac. Sci. Technol (2002) 531-536 "Recent advances in resists for 157 nm microlithography" Francis W. Michelotti and J. H. Carter, J.Am. Chem. Soc. (1965) 224-233 "Polymerization of Norbornene and Derivatives. II. Selectivity in the Polymerization of Exoisomers П by Iridium Catalysis" Daniel p. Snaders, Eric F. Connor, and Robert H. Grubbs, Macromolecules 2002, Vol 35, 6539-6549 Itan. American Chemical Society,
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